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Marulanda-Bernal, José-Ignacio; Gallo-Castrillón,
Wilson-Henry; Mosquera-Palacio, Diana-Marybel
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Microwave Frequency Characterization of Barium Titanate Films Obtained Via Sol-Gel

José-Ignacio Marulanda-Bernal¹

Wilson-Henry Gallo-Castrillón²

Diana-Marybel Mosquera-Palacio³

Abstract

The present work focuses on the structural, morphological and dielectric characterization of barium titanate films (BTO or BaTiO₃ due to its chemical formula) deposited by spin coating on crystalline silicon (Si) substrates and CPW resonators using the Sol-Gel technique with a Ba/Ti molar ratio of 0.5/0.5. The coplanar waveguides were manufactured on alumina substrates (Al₂O₃) with 3 μm of gold (Au) metallization using the laser ablation technique. The scanning electron microscopy (SEM) with X-ray energy dispersion spectrometry (EDS) showed the existence of a BTO film with an elementary composition of 14.62% barium and 5.65% titanium, with a thickness of 0.77 μm measured using the profilometric mode of the atomic force microscopy (AFM). Dielectric characterization was carried out by comparing the frequency response (parameter S_{21}) of a CPW resonator with deposited BTO film and another reference resonator (without film) using a network vector analyzer (VNA). These measurements are compared in turn with computational simulations to obtain the dielectric properties. For the BTO film a relative dielectric constant (ϵ_r) of 160 was determined with a loss tangent ($\tan\delta$) of 0.012 for a frequency of 3.60

¹ Ph. D. Universidad EAFIT (Medellín-Antioquia, Colombia). jmarulan@eafit.edu.co. ORCID: [0000-0001-6233-3407](https://orcid.org/0000-0001-6233-3407).

² M. Sc. Universidad EAFIT (Medellín-Antioquia, Colombia). whgalloc@eafit.edu.co. ORCID: [0000-0001-9196-7644](https://orcid.org/0000-0001-9196-7644).

³ Universidad EAFIT (Medellín-Antioquia, Colombia). dmmosquerp@eafit.edu.co. ORCID: [0000-0003-0401-3557](https://orcid.org/0000-0003-0401-3557).

GHz. The dielectric constant and the ferroelectric property of the material produced are quite promising for applications in microwave circuits, such as miniaturization and tuning.

Keywords: dielectric constant; ferroelectrics; microwave materials; loss tangent; Sol-Gel; thin films.

Caracterización en frecuencia de microondas de películas de titanato de bario obtenidas vía Sol-Gel

Resumen

El presente trabajo se centra en la caracterización estructural, morfológica y dieléctrica de películas de titanato de bario (BTO o BaTiO_3 por su fórmula química) depositadas mediante la técnica que proporciona recubrimiento por medio de un sistema de rotación (*spin coating*) sobre sustratos de silicio cristalino (Si) y resonadores CPW a través del método Sol-Gel, utilizando una relación molar Ba/Ti de 0.5/0.5. Las guías de ondas se fabricaron sobre sustratos de alúmina (Al_2O_3) con 3 μm de metalización en oro (Au) empleando la técnica de ablación láser. La microscopia electrónica de barrido (SEM) con espectrometría de dispersión de energía de rayos X (EDS) permitió evidenciar la existencia de una película de BTO con una composición elemental de 14.62 % de bario y 5.65 % de titanio, además de un espesor de 0.77 μm medido utilizando la modalidad perfilométrica de la microscopia de fuerza atómica (AFM). La caracterización dieléctrica se llevó a cabo mediante la comparación de la respuesta en frecuencia (parámetro S_{21}) de un resonador CPW con película de BTO depositada y otro resonador de referencia (sin película) usando un analizador vectorial de red (VNA). Estas medidas se comparan a su vez con simulaciones computacionales para obtener las propiedades dieléctricas. Para la película de BTO se determinó una constante dieléctrica relativa (ϵ_r) de 160 con tangente de pérdida ($\text{Tan}\delta$) de 0.012 para una frecuencia de 3.60 GHz. La constante dieléctrica y la propiedad ferroeléctrica del material elaborado son características bastante promisorias para aplicaciones en circuitos de microondas, tales como miniaturización y sintonizabilidad.

Palabras clave: constante dieléctrica; ferroelétricos; materiales en microondas; películas delgadas; Sol-Gel; tangente de pérdida.

Caracterização e Frequência de Micro-ondas de Películas de Titanato de Bário Obtidas Via Sol-Gel

Resumo

O presente trabalho centra-se na caracterização estrutural, morfológica e dielétrica de películas de titanato de bário (BTO ou BaTiO_3 por sua fórmula química) depositados mediante a técnica que proporciona recobrimento por meio de um sistema de rotação (*spin coating*) sobre substratos de silício cristalino (Si) e ressonadores CPW mediante a técnica Sol-Gel, utilizando uma relação molar Ba/Ti de 0.5/0.5. As guias de ondas fabricaram-se sobre substratos de alumina (Al_2O_3) com 3 μm de metalização em ouro (Au) empregando a técnica de ablação laser. A microscopia eletrônica de varredura (SEM) com espectrometria de dispersão de energia de raios X (EDS) permitiu evidenciar a existência de uma película de BTO com uma composição elemental de 14.62 % de bário e 5.65 % de titânio, ademais de uma espessura de 0.77 μm medido utilizando a modalidade perfilométrica da microscopia de força atômica (AFM). A caracterização dielétrica levou-se a cabo mediante a comparação da resposta em frequência (parâmetro S_{21}) de um ressonador CPW com película de BTO depositada e outro ressonador de referência (sem película) usando um analisador vectorial de rede (VNA). Estas medidas compararam-se a sua vez com simulações computacionais para obter as propriedades dielétricas. Para a película de BTO determinou-se uma constante dielétrica relativa (ϵ_r) de 160 com tangente de perda ($\text{Tan}\delta$) de 0.012 para uma frequência de 3.60 GHz. A constante dielétrica e a propriedade ferroelétrica do material elaborado são características bastante promissoras para aplicações em circuitos de micro-ondas, tais como miniaturização e sintonizabilidade.

Palavras chave: constante dielétrica; ferroelétricos; materiais em micro-ondas; películas finas; Sol-Gel; tangente de perda.

I. INTRODUCTION

Ferroelectric materials are characterized for presenting a spontaneous polarization in absence of an electric field [1]. This particularity has brought electronic industries to use these materials in the GHz region for the optimization and miniaturization of measurement devices, frequency and telephony analyzers [2]. One of the most common ferroelectric materials applied in microwave frequency tuning is the barium titanate (BTO or BaTiO_3 for its chemical formula) [3-7]. Said process can be made by depositing films of the material through Sol-Gel synthesis on resonators elaborated in Coplanar Waveguides (CPW) [8-9].

The So-Gel process consists in the preparation of a colloid stable solution ("Sol") from de precursors that produce a network of macromolecular oxide, that gels into a film when it dries [10-11]. Authors such as O. Harizanov *et al*, S. Sharma *et al*, y D. Tripkovic *et al*, used the Sol-Gel synthesis to obtain slim BTO films through deposition techniques such as dip coating, spin coating and Inkjet, respectively [10, 12-13]. In this paper the dielectric characterization of BTO is presented, so that it is possible to ensure a high ϵ_r under acceptable structural and morphological conditions.

II. METHODS

A. Preparation of the BTO via Sol-Gel

The procedure was adapted in a humid way and at room temperature (22 °C) for the Sol-Gel method reported by Balachandran *et al* [14], using as precursor the titanium isopropoxide (IV) or TTIP (Alfa A13703) and the barium acetate (Merck). In this sense, 0.387 g of barium acetate were mixed with 3.0 ml of deionized water with constant agitation of 320 rpm, until the barium acetate was completely dissolved (solution 1). Then, 3.0 ml of acetic acid were added to 0.468 ml of TTIP until a homogenous mix was obtained (solution 2). Later, both solutions were mixed with a molar proportion Ba/Ti of 0.5/0.5. Then, ethylene glycol was added in a 1.1 relation to acetic acid.

The BTO deposition was made at room temperature (22 °C) over crystalline silicon and CPW resonators, using a spin coater at 2000 rpm during five seconds. The

recovered substrates dried at room temperature and were submitted to a thermic treatment with rising temperature of 400 °C (1 °C/min), maintained at 900°C (5 °C/min) during an hour, then cooled down by natural convection during 12 hours until they reached room temperature.

B. Characterization of BTO films

1) Atomic force microscopy. The measurement of the width for the crystalline silicon substrates and CPW resonators with BTO film was made using the intermittent contact mode without previous preparation of the sample. In order to do that, a Nanosurf ® microscope model Easyscan2 AFM was used, occupying a CT170R-25 probe with a conic form 15 µm high, curvature ratio of 8 nm and resonance frequency of 170kHz.

2) Sweep electronic microscopy. The analysis of sweep electronic microscopy (SEM) allowed us to determine the morphology of the BTO without a special preparation of the sample. A Phenom G2 pro® microscope was used with a 7kV voltage.

3) X-ray energy dispersion spectroscopy. The EDS analysis gave information about the elemental composition of the evaluated material, through the use of a thermionic JEOL-JSM 6490LV® microscope with a 16kV voltage. Before making the analysis, the samples were covered with gold through sputtering process.

4) Dielectric characterization. To perform the dielectric characterization CPW resonators as described by Marulanda *et al* [15] were elaborated. The Figure 1a shows the structural dimensions of the CPW that consist of a central conducting line (s), two ground planes (g), gap (w), a gold metallization thickness (f), an alumina polished substrate that covers all of the height h and with relative permittivity ($\epsilon_r = 9.8$). Additionally, the parameters a, b and c are shown, which make reference to the geometric parameters of the CPW. With the previous parameters, the design was defined (Figure 1b), to later elaborate the configuration model in CAD and use a LPKF ProtoMats® plotter to fabricate the CPW resonators (Figure 2).

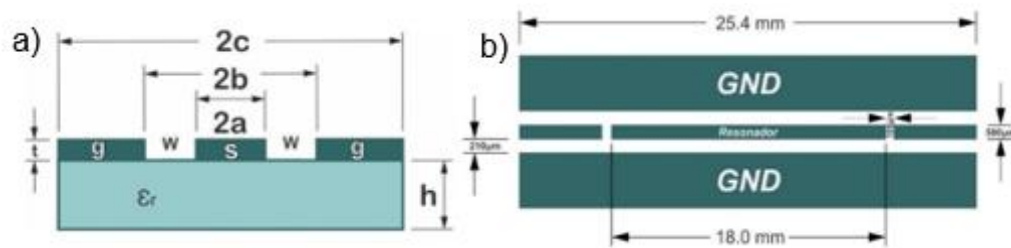


Fig. 1 CPW Transmission line a) Transversal section, b) Experimental design.

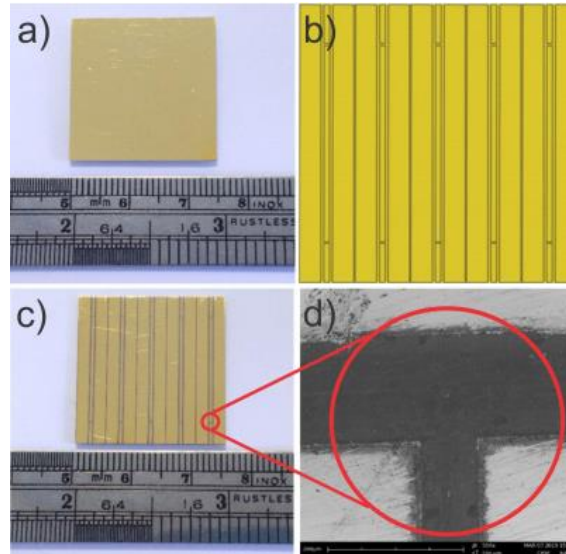


Fig. 2 Elaboration of CPW resonators. A) Superficial view of the dielectric substrate, b) CAD design of the CPW transmission line, c) Plot over the dielectric substrate, d) SEM image of the plot.

1.00 mm of each border of the CPW circuit was isolated with vacuum and high temperature tape (Figure 3), to measure the thickness and correctly make the connections to the vector network analyzer.

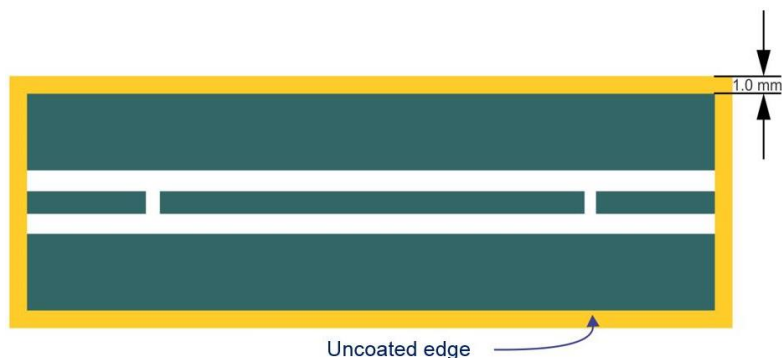


Fig. 3 Isolated borders of the CPW resonator.

5) Frequency Response of the resonator circuits. An Agilent E5063A® VNA of two ports was used with a measuring range between 0.1 and 8.5 GHz, and without previous preparation of the circuits that were joined to a RP SMA type coaxial ensemble (Figure 4). The measuring of the frequency response of the CPW+DUT was made for resonators with and without the BTO film, to avoid the displacement in the measures of the S parameters.

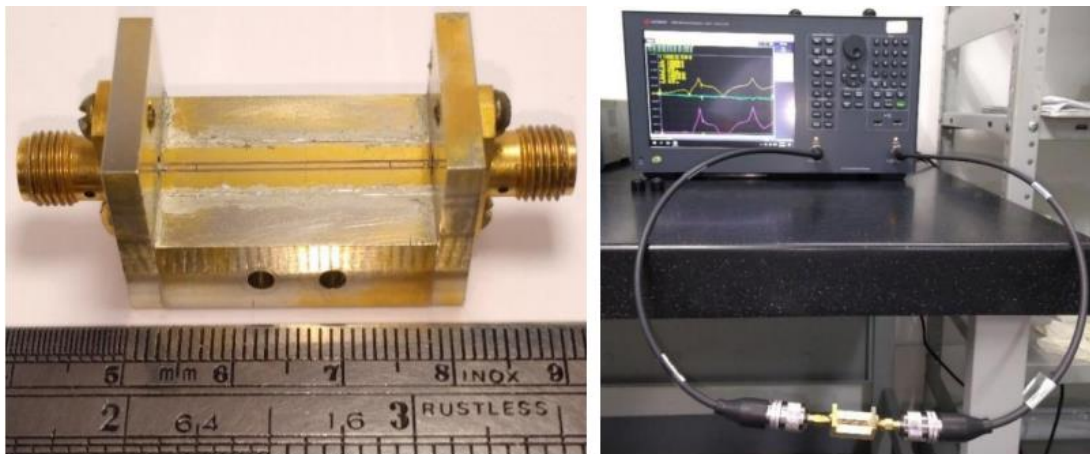


Fig. 4 Dielectric Characterization. a) CPW resonator located in a RP SMA type coaxial ensemble, b) Vector network analyzer.

III. RESULTS

A. Structural and Morphological Characterization

In Figure 5a it is shown by the difference in the tonality the presence of the BaTiO₃ film with a thickness of 0.77 μm (770 nm); superficial defects or scratches can be seen, generated by the action of the laser during the CPW circuit impression process (Figure 3d). Figure 5b depicts the BaTiO₃ film with the presence of separated nanoparticles with spherical shapes and average size of $4.10 \pm 0.46 \mu\text{m}$ (4100 ± 460 nm).

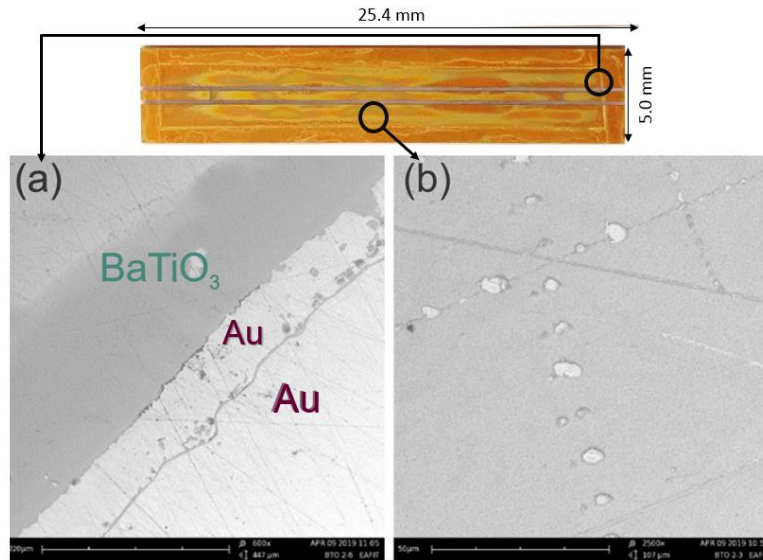


Fig. 5. BaTiO₃ film morphology. a) Interface between the gold metallization (right) of the CPW resonator and the BaTiO₃ film (left), b) BaTiO₃ film deposited on the CPW resonator.

The EDS analysis was made for BTO layers deposited on a crystalline silicon substrate, these layers added a net thickness of 0.55 μm (550 nm). In Figure 6 it can be seen for the BTO layers deposited on a superficial morphology which is granular and composed of individual particles with homogeneous sizes of approximately $0.71 \pm 0.37 \mu\text{m}$ ($710 \pm 370 \text{ nm}$), which is attributed to the liquid phase synthesis process [7]. The elemental EDS analysis shows an elemental composition in atomic percentage of 14.62 % Ba (L), 79.73 % O (K) y 5.65 % Ti (K).

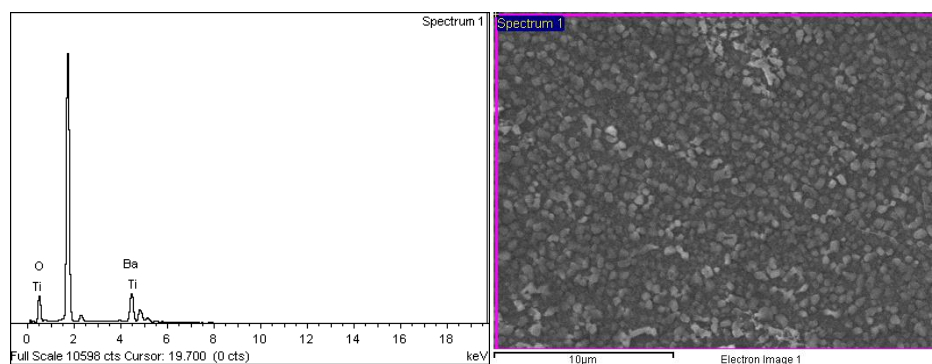


Fig. 6 EDS analysis for BTO films deposited on crystalline silicon substrate.

B. Dielectric Characterization

Figure 7 depicts the peaks of resonance obtained through the comparison of the S_{21} parameter measurements done with the VNA analyzed for the CPW with and without BTO film. By making a close up to the first peak with resonance frequency of 3.60 GHz, a light displacement to a lower frequency of the CPW resonator with BTO film can be seen. Through simulations made with CST Microwave Studio Suite®, a dielectric relative constant (ϵ_r) of 160 was determined for the covering material (BTO) and a $\tan\delta$ of 0.012. These results have similarities with those reported by [16], who obtained a dielectric constant of 120 to 10 kHz for thin BTO films deposited by RF magnetron sputtering. Here it can be highlighted that the process of obtaining the particles defines the final dielectric characteristics of the material.

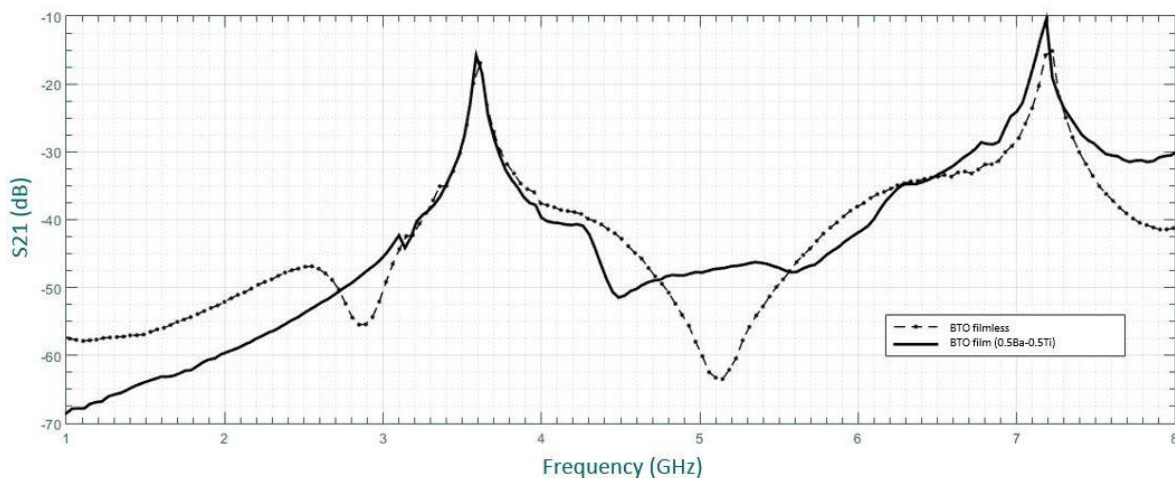


Fig. 7. Fundamental resonance peaks measured on CPW resonators with and without BTO content.

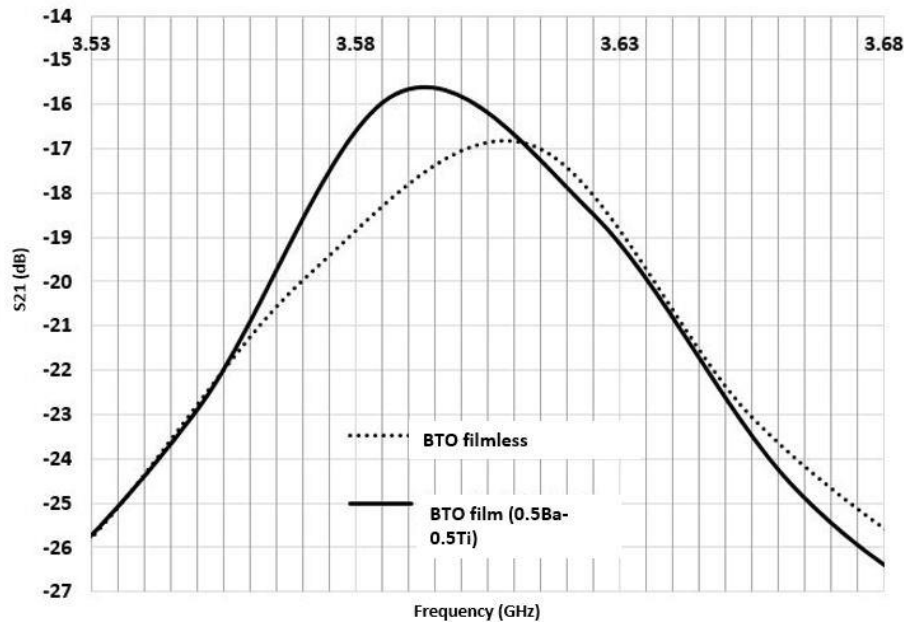


Fig. 8 Close up to the first peak of fundamental resonance of the CPW resonator with and without BTO content.

IV. DISCUSSION AND CONCLUSIONS

In the present paper, structural, morphological and dielectric characteristics of BTO films deposited on CPW resonators through the Sol-Gel technique are reported. Thicknesses of BTO film deposited on crystalline silicon substrates and CPW resonators of 0.55 μm (550 nm) and 0.77 μm (770 nm) respectively were obtained. Additionally, a dielectric relative constant (ϵ_r) of 160 was determined for the BTO film, as well as a loss tangent ($\tan\delta$) of 0.012 for a resonance frequency of 3.60 GHz, dielectric characteristics that are of particular interest for microwave applications.

AUTHOR'S CONTRIBUTION

Marulanda-Bernal was the generator of the central idea of the investigation and the supervisor of the experimental processes performed and the results obtained; Gallo-Castrillón executed the experiments related with the fabrication of the CPW circuit and the preparation of the BTO films; and Mosquera-Palacio collaborated in the performances of the experimental Sol-Gel process to obtain the BTO films.

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